

FIG. 3

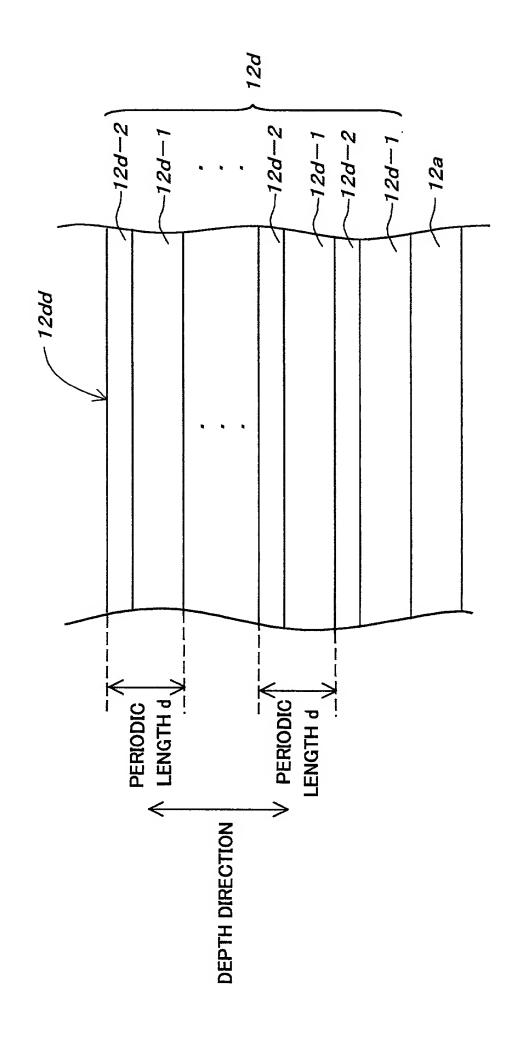
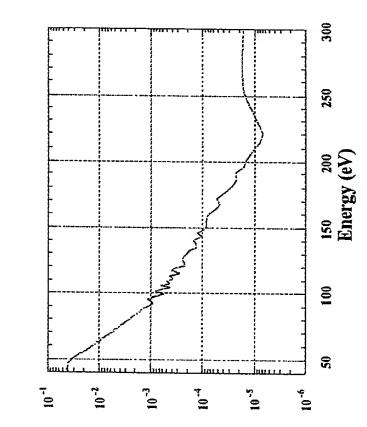


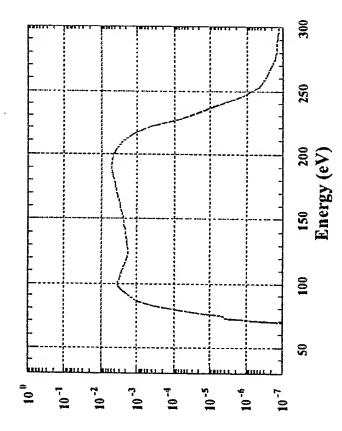
FIG. 4(a)

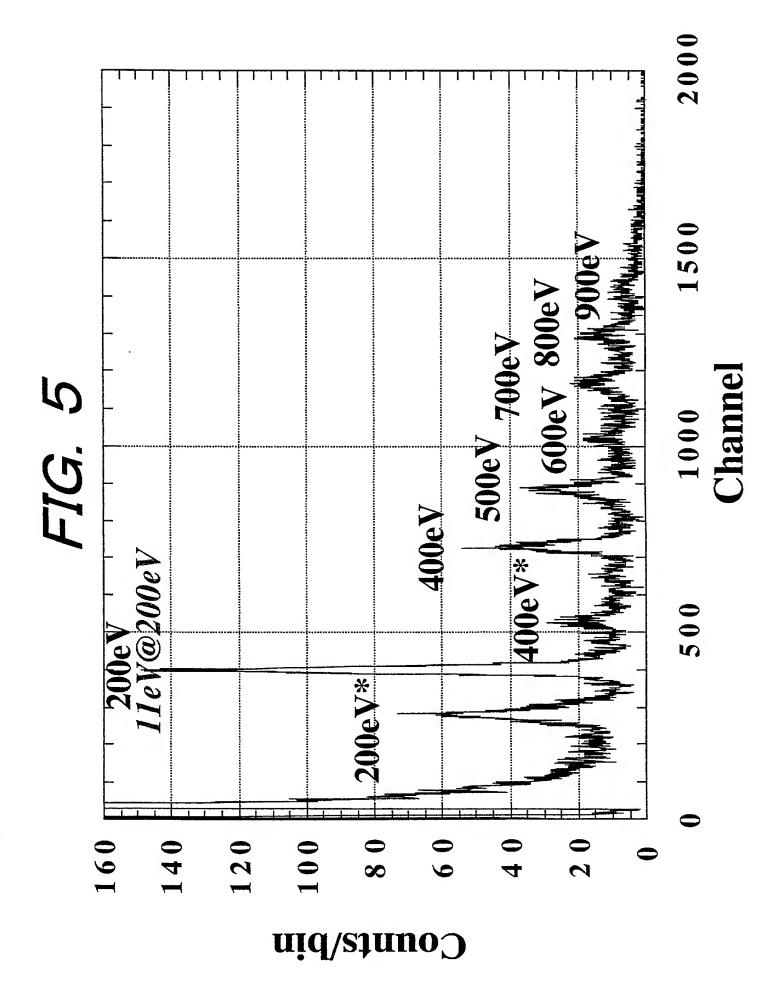


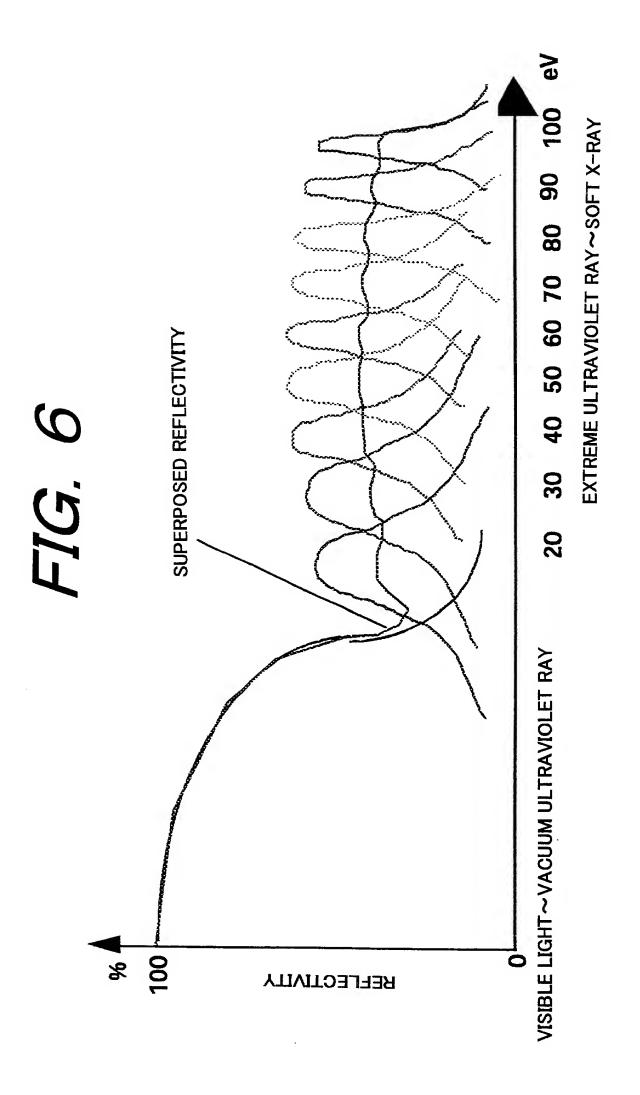
Reflectivity

Тгапатійнапсе

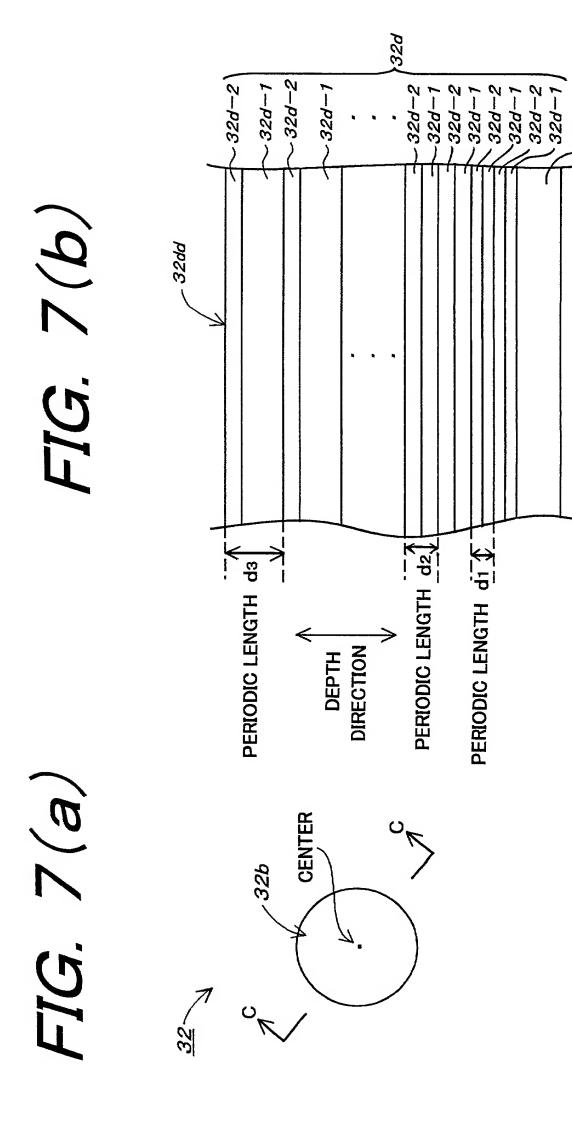






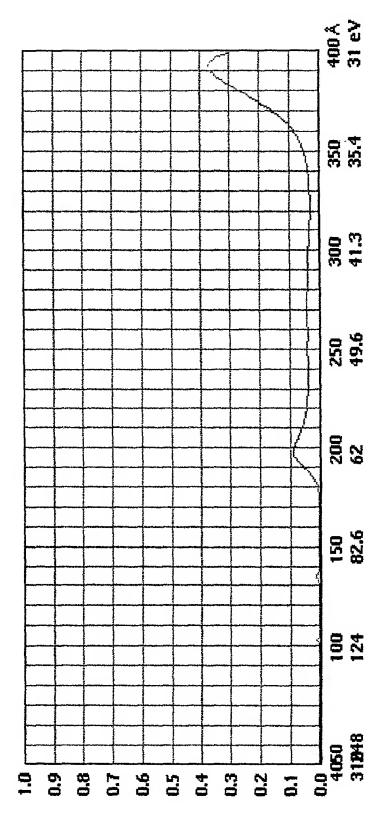


SYNTHESIZED REFLECTIVITY CHARACTERISTICS OF MULTILAYER FILM REFLECTING MIRROR

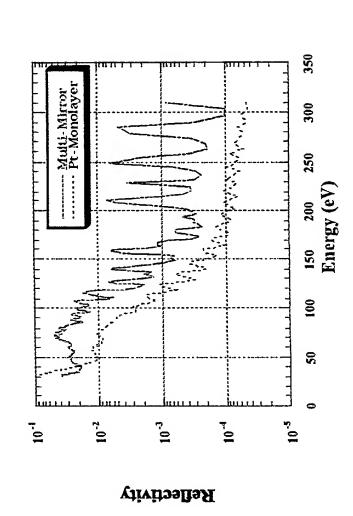


NUMBER	MATERIAL1	MATERIAL2	VALUE d	VALUE γ	NUMBER OF PAIR LAYER	THEORETICAL CALCULATION1	THEORETICAL CALCULATION2
1	Мо	Mg2Si	170	50	20	0	0
2	Мо	Mg2Si	190	50	20	0	0
3	Мо	Mg2Si	210	40	20	0	0
4	Мо	Si	115	50	20	0	0
5	Мо	Si	140	50	20	0	0
6	Мо	Si	55	50	20	0	0
7	Мо	Si	60	50	20	0	0
8	Мо	Si	65	50	20	0	0
9	Мо	Si	65	70	20	0	0
10	Мо	Si	70	70	20	0	0
11	Мо	Si	75	70	20	0	0
12	Мо	Si	80	50	20	0	0
13	Ni	С	22	40	200	0	×
14	Ni	C	25	40	200	0	×
15	Ni	C	30	40	200	0	×
16	Ni	C	40	30	30	0	×
17	Ni	C	45	30	30	0	×
18	Ni	C	50	30	30	0	×
19	Ni	С	55	30	30	0	×
20	Ni	C	60	30	30	0	X
21	Мо	Si	85	50	20	0	0
22	Мо	Si	90	50	20	0	0
23	Мо	Si	95	50	20	0	0

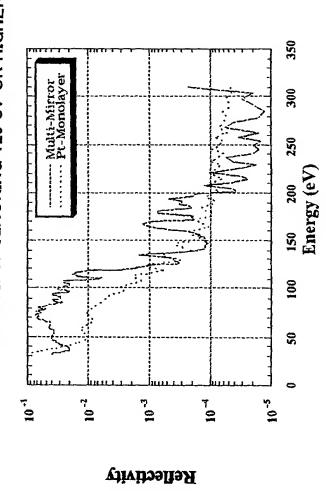
FIG. 9

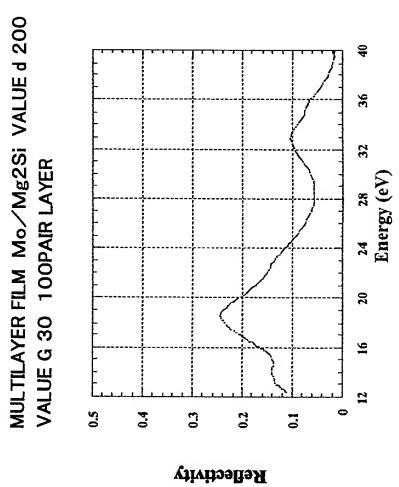


COMPARISON OF SYNTHESIZED REFLECTIVITY IN MULTILAYER FILM WITH REFLECTIVITY IN Pt MONOLAYER FILM



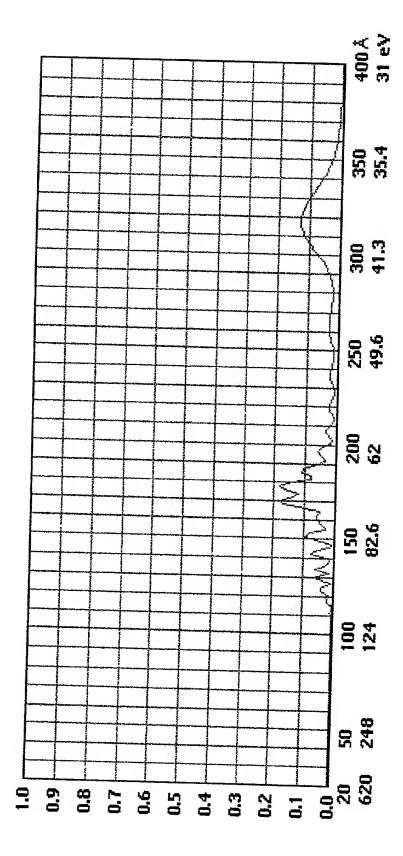
COMPARISON OF SYNTHESIZED REFLECTIVITY WITH REFLECTIVITY IN Pt MONOLAYER IN CASE OF IGNORING 125 eV OR HIGHER





NUMBER	NUMBER MATERIALI	MATERIAL 2	INITIATION VALUE d	INITIATION TERMINATION VALUE d VALUE d	VALUE 7	NUMBER OF PAIR LAYER
F	Mo	S.	170	50	30	20
8	2 Mo	Z.	190	50	50	20
ന	Mo	S:	210	50	35	20
4	No	S	115	50	25	20
Ŋ	Ş ¥	S	140	20	20	100

FIG. 14



COMPARISON OF SYNTHESIZED REFLECTIVITY IN SUPERMIRROR WITH REFLECTIVITY IN Pt MONOLAYER FILM

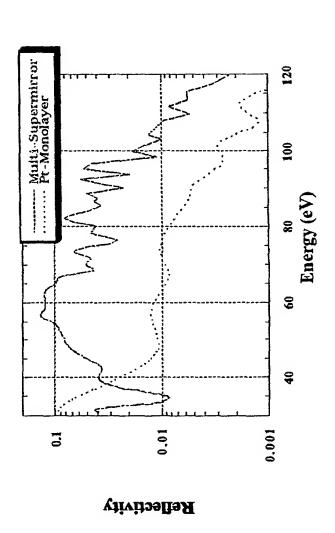
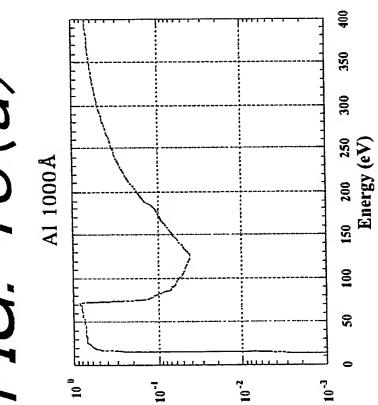


FIG. 16(a)

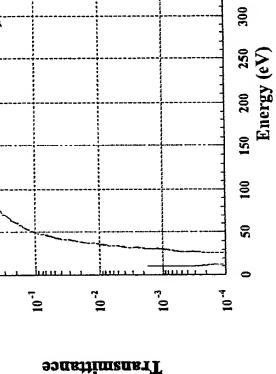
FIG. 16(b)

10 ₀



Transmittance





400

350

FIG. 17(a) FIG. 17(b)

